

S/N TBD  
Docket: CS02-090  
Group art unit : \_\_\_ TBD

Date October 1, 2003

To: Commissioner of Patents and Trademarks  
P.O. Box 1450 Alexandria, VA 22313-1450

Fr: William J. Stoffel Reg. No. 39,390 Cust No. 30402  
PMB 455  
1735 Market St - Suite A  
Philadelphia, PA 19103

Subject:

Serial No. TBD  
Docket cs02-090  
File Date: with application  
Inventor: Yang et al.

**title: Method for forming a MIM capacitor**

Group art unit: TBD

#### INFORMATION DISCLOSURE STATEMENT

Enclosed is Form PTO A820 (also PTO-1449), Information  
Disclosure Citation and references.

#### CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the  
United States Postal Service as first class mail in an envelope addressed  
to: Commissioner for Patents, P.O. Box 1450 Alexandria, VA 22313-1450, on  
oct 2 , 2003.

Signature/Date W J Stoffel 10/2/03

William J. Stoffel Reg. No. 39,390  
Customer number 30402

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The following Patents and/or Publication are submitted to  
comply with the duty to disclose under CFR 1.97-1.99 and 37  
CFR 1.56.

US 6,387,750B1(Lai et al.) shows a process for a MIM  
capacitor.

US 6,559,004b1(Yang et al.) shows a process for forming  
a MIM capacitor.

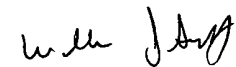
US 6,468,873b1(Lui et al) shows a CU MIM process.

US 2002/0019123A1 - Ma et al. discloses a Cu MIM process.

US 6,426,250 (Lee,et al.) shows a High density stacked  
MIM capacitor structure.

US 6,451,650 (Lou) discloses a Low thermal budget method  
for forming MIM capacitor.

Sincerely,



William J. Stoffel  
Reg. No. 39,390  
Customer number 30,402

<b>INFORMATION DISCLOSURE CITATION</b> <i>(Use several sheets if necessary)</i>				Docket Number (Optional) <b>Cs02-090</b>		Application Number	
				Applicant(s) <b>Tang et al.</b>			
				Filing Date <b>tbd</b>		Group Art Unit <b>tbd</b>	

U.S. PATENT DOCUMENTS							
*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		US 6,387,750B1		Lai et al.)			
		US 6,559,004b1		Yang et al.)			
		US 6,468,873b1		Lui et al			
		US 2002/0019123A1		Ma et al			
		US 6,426,250		Lee,et al.)			
		US 6,451,650		Lou			

FOREIGN PATENT DOCUMENTS								
REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation		
						YES	NO	

OTHER DOCUMENTS <i>(Including Author, Title, Date, Pertinent Pages, Etc.)</i>		

EXAMINER	DATE CONSIDERED
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.